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# Electrochemical Water Treatment Using Boron Doped Diamond Film Electrodes

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# Outline

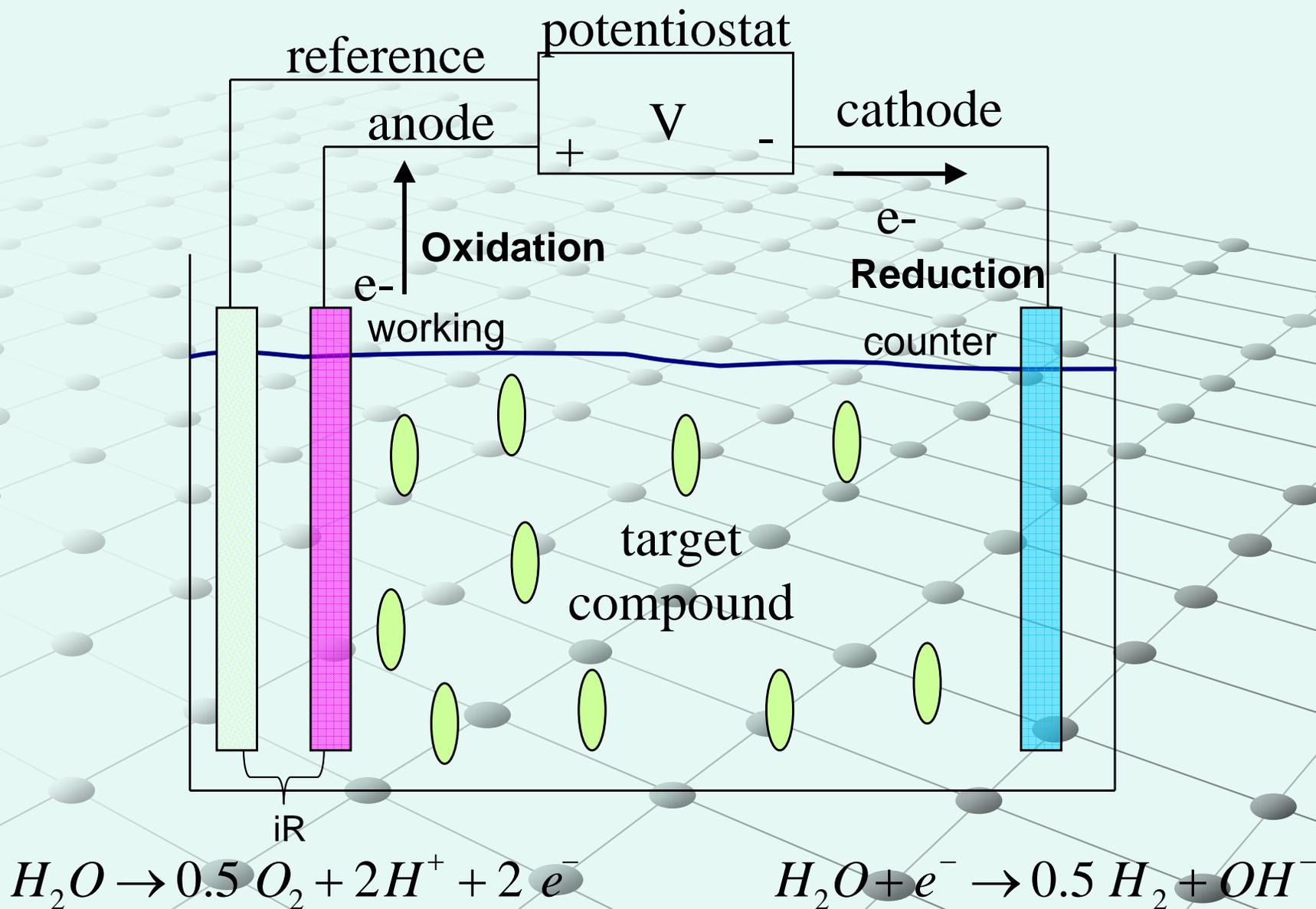
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- Background
  - Common treatment technologies
  - Three Electrode cell
  - Electron transfer mechanisms
  - Advantage of BDD electrodes
- Treatment of CMP wastewaters
  - Reduction of  $\text{Cu}^{2+}$
  - Oxidation of Citrate
- Treatment of PFOS wastewaters
- Conclusions

# Treatment Technologies

1. Adsorption - activated carbon, zeolites
  2. Ion Exchange
  3. Air stripping
  4. Membranes - reverse osmosis
  5. Biological treatment - aerobic, anaerobic
  6. Chemical Oxidation – UV or  $O_3/H_2O_2$
  7. Electrochemical reduction/oxidation
- Disposal issues
- Destructive removal
-

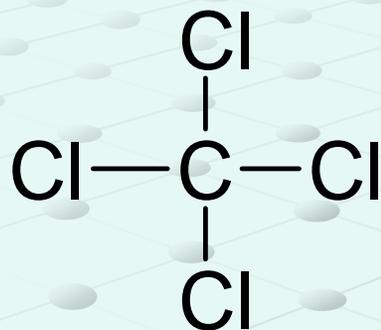
# Three Electrode Cell



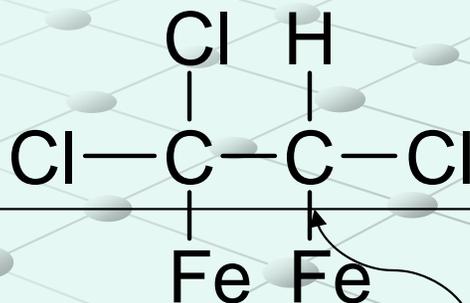
## Competing Reactions

# Reduction - Electron Transfer Mechanisms

## Direct Electron Transfer



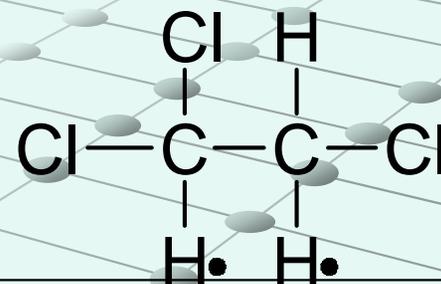
$e^-$   
tunneling  
to physically  
adsorbed species



chemisorbed  
species

**Cathode**

## Indirect Electron Transfer



reduction via  
atomic hydrogen  
produced from  
water reduction

# Water Oxidation

All Electrode:



Active Electrode:

(IrO<sub>2</sub>; RuO<sub>2</sub>)

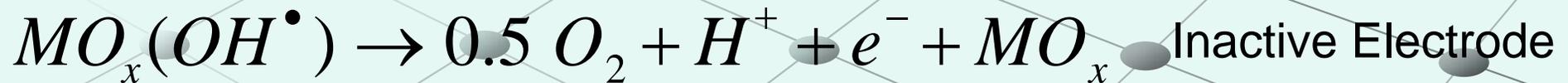


Inactive Electrode:

(BDD; PbO<sub>2</sub>; SnO<sub>2</sub>)



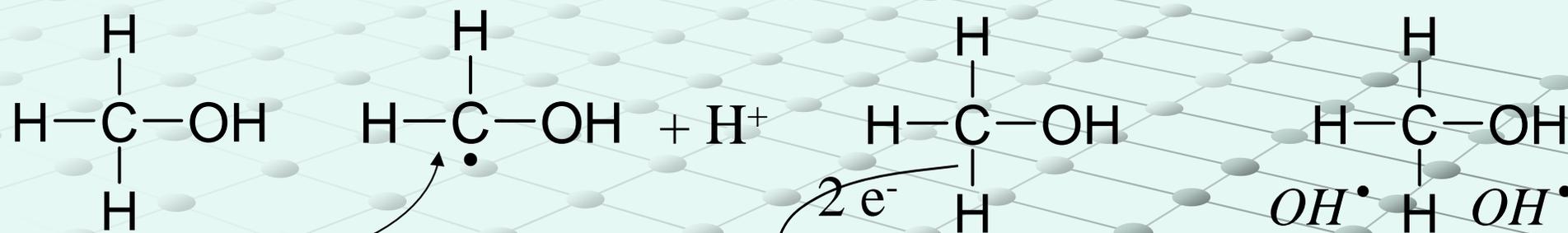
- MO<sub>x</sub> is a metal oxide site on the anode surface.
- Water oxidation produces adsorbed OH<sup>•</sup> radicals.
- Active oxygen species (MO<sub>x</sub>(OH<sup>•</sup>) and MO<sub>x+1</sub>) may oxidize organic compounds.
- High concentrations of active oxygen species lead to O<sub>2</sub> evolution.



# Oxidation - Electron Transfer Mechanisms

## Direct Electron Transfer

## Indirect Electron Transfer



hydrogen abstraction  
from adsorbed species

$e^-$



oxidation by  
active oxygen

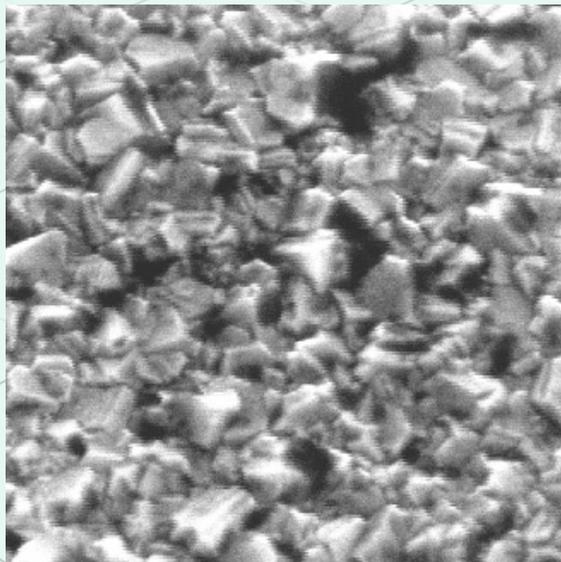


oxidation by  
hydroxyl radicals

**Anode**

# Boron-Doped Diamond Film (BDD) Electrodes

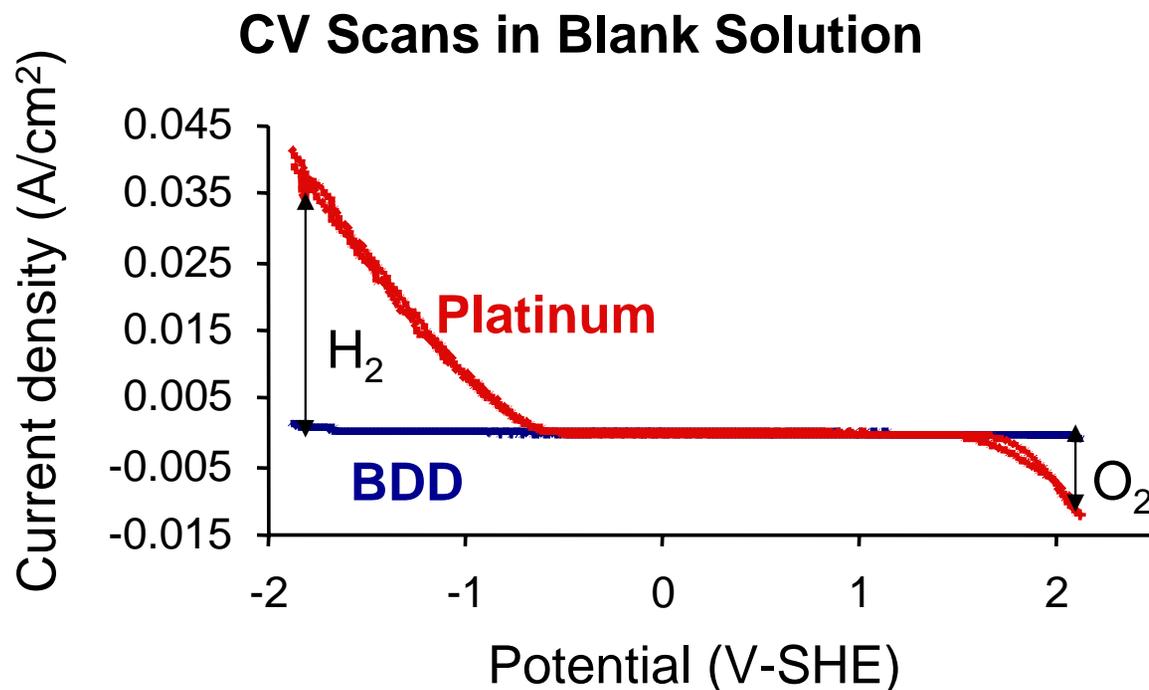
- Diamond film grown on p-silicon substrate using chemical vapor deposition (CVD) technique
  - P-silicon polished with a diamond containing paste, serving as nucleation sites
  - Microwave radiation or a hot filament used to decompose gas mixture of methane and hydrogen
  - Boron doping:  $B_2H_6$
- Boron doping provides electrical conductivity



Scanning electron micrograph of BDD electrode. The individual diamond crystals are  $\sim 0.5 \mu m$  in size.

# BDD Electrodes: Advantages

- Nonactive electrodes: capable of complete mineralization to  $\text{CO}_2$ .
- Highly stable under anodic and cathodic polarization
- Very low catalytic activity for oxygen and hydrogen evolution: wide electrochemical window for water oxidation and reduction.
- High mechanical strength and resistance to chemical attack
- Hydrophobicity



# BDD Electrode: Applications

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- nitrate reduction to ammonia (Bouamrane, *et al.*, 1996)
- organic compound oxidation in wastewater (Gyorgy *et al.*, 1999)
- metal ion quantification (Ramesham, 1999)
- metal ion removal (Perret, *et al.*, 1999)
- cathodic hydrogen peroxide generation (Goeting, *et al.*, 1999)
- ozone generation (Katsuki, *et al.*, 1998)
- peroxodisulfuric acid generation (Michaud, *et al.*, 2000)
- glucose, ethanol and COD sensors (Rychen, *et al.*, 2001)

# Experimental Systems



Rotating disk electrode (RDE) in batch reactor.

- no mass transfer limitations
- electrode surface area =  $1 \text{ cm}^2$
- solution volume = 350 mL
- $a_s = 0.00286 \text{ cm}^2/\text{mL}$

Parallel plate flow-cell.

- rates similar to real treatment process
- electrode surface area =  $25 \text{ cm}^2$
- solution volume = 15 mL
- $a_s = 1.67 \text{ cm}^2/\text{mL}$

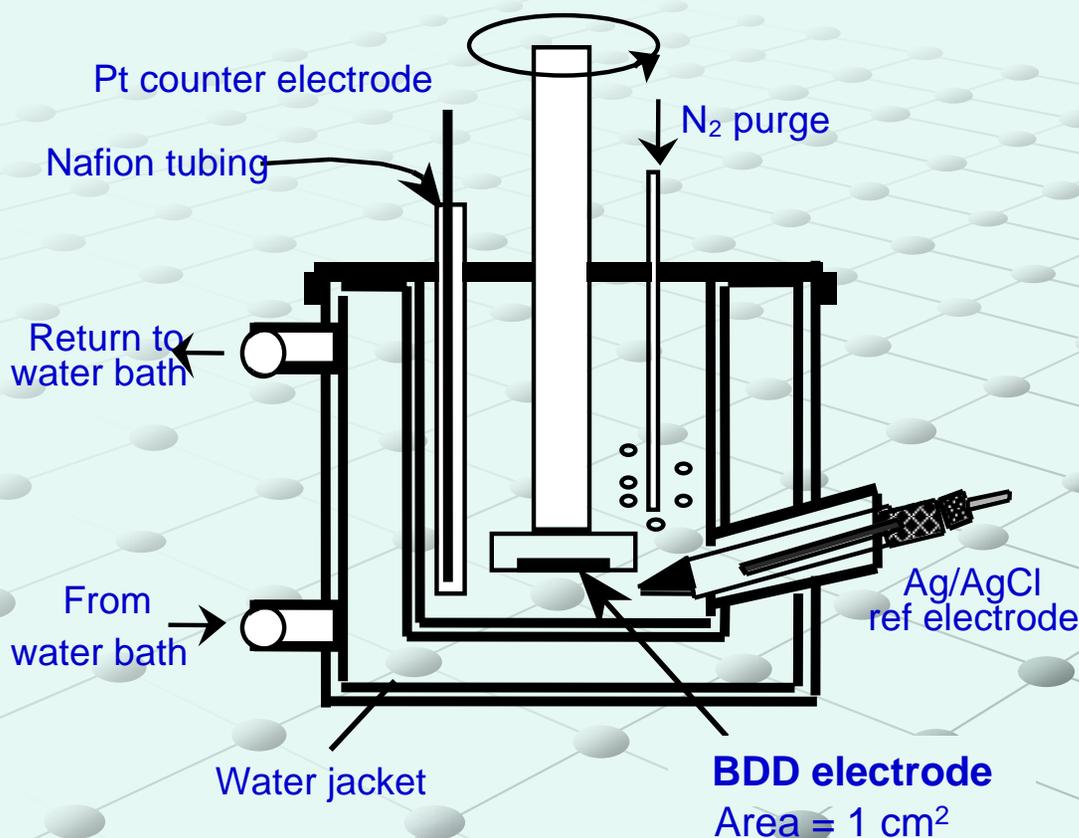
# Example: Treatment of CMP Wastewater

- Chemical-mechanical planarization (CMP): key technology in ultra large-scale integration device manufacturing
- Complex waste mixture consisting of suspended solids,  $\text{Cu}^{2+}$  ions, chelating agents, corrosion inhibitor and other additives
- Current treatment technologies: several sequential unit operations  
(Expensive)
  - Coagulation/flocculation (additional chemicals introduced)
  - Filtration
  - Ion-exchange
  - Regeneration of the ion exchange resin (secondary waste stream)
- Electrochemical methods: simpler and cost effective
  - Cathodic decomposition to remove  $\text{Cu}^{2+}$  ions
  - Anodic decomposition to remove corrosion inhibitors and organic complexing agents.
  - Filtration after coagulation induced by acidic environment generated by anodic reaction

Tamilmani, S.; Hung, W. H.; Raghavan, S.; Farrell, J. *IEEE transactions on Semiconductor manufacturing*, 17, 448-454 (2004).



# CMP Wastewater Treatment: Batch Experiments



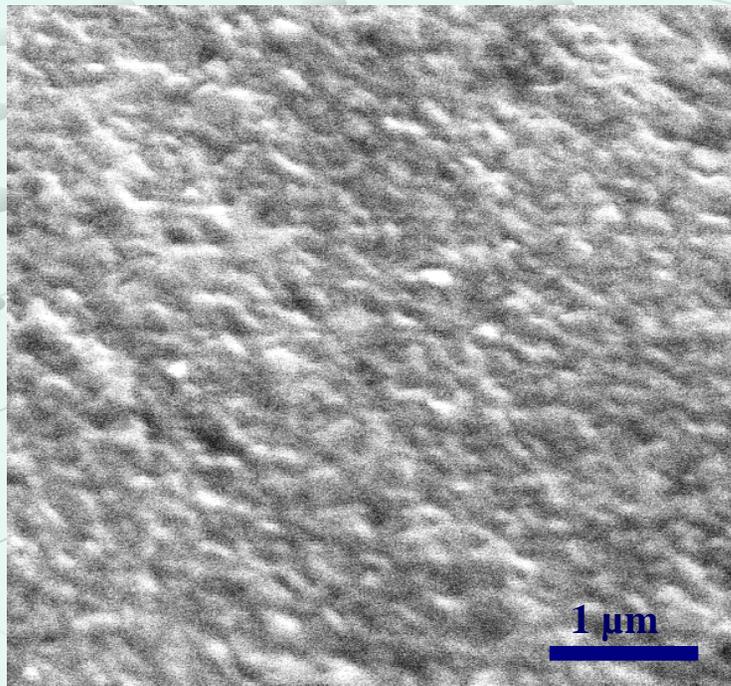
**Rotating Disk Electrode (RDE) Reactor**

- Electrode rotated at 100 rpm
- Reactor volume = 30 mL
- EG&G model 273 A potentiostat
- Copper ions determined by AAS
- Citrate ions determined by IC
- TOC removal determined by combustion /IR

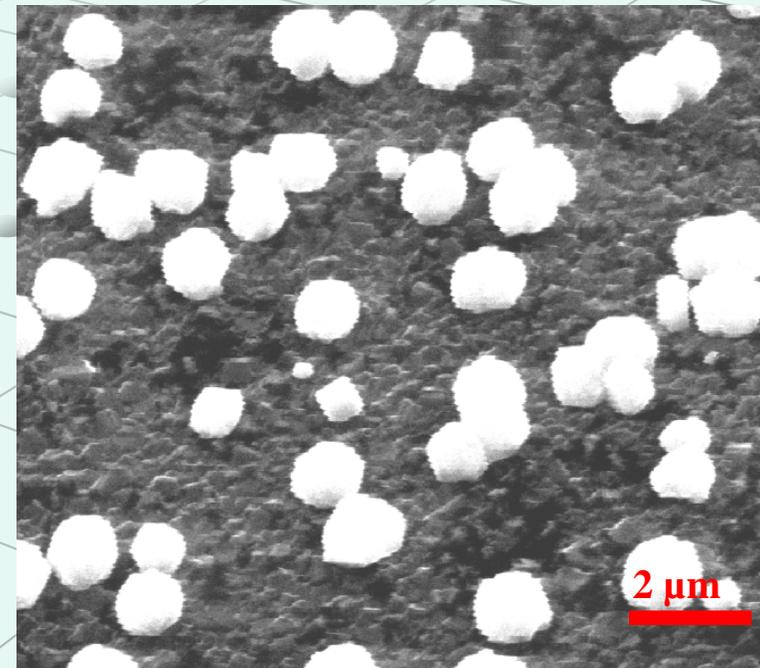
# SEM Micrographs of Copper Deposits

Copper deposits obtained after 90 minutes of polarization at -200 mV-Ag/AgCl in a 50 mM  $K_2SO_4$  solution containing 20 mg/L copper.

**Copper on Copper Electrode**



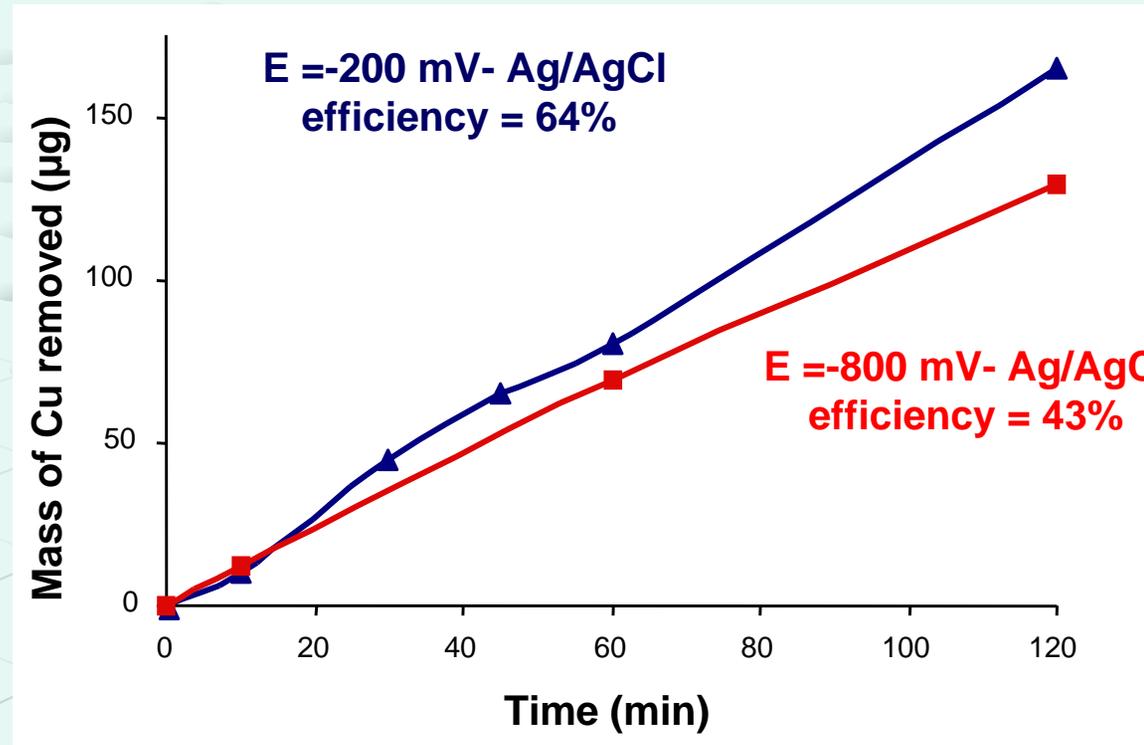
**Copper on BDD Electrode**



Discrete particles suggests discrete active sites.

# Effect of Potential on $\text{Cu}^{2+}$ Removal

$\text{Cu}^{2+}$  removal in batch RDE reactor at 100 rpm.

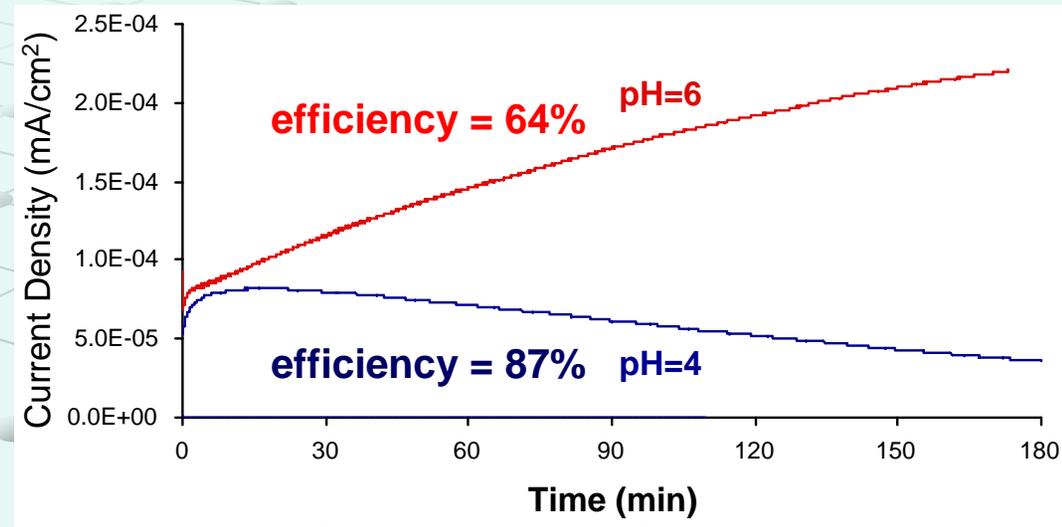
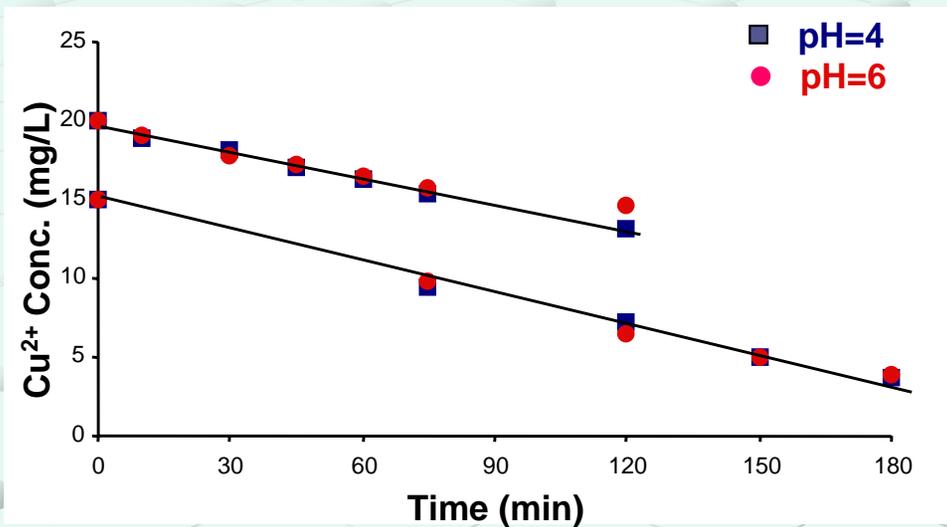


- Slower removal at lower potential due to increased blocking effect of hydrogen bubbles.
- Weak effect of potential suggests mass transfer limited removal.
- Removal rate = mass transfer limited flux for  $d=45 \mu\text{m}$ .

# Effect of pH on $\text{Cu}^{2+}$ Removal

Concentrations in batch RDE reactor at 100 rpm for  $E = -200 \text{ mV-Ag/AgCl}$ .

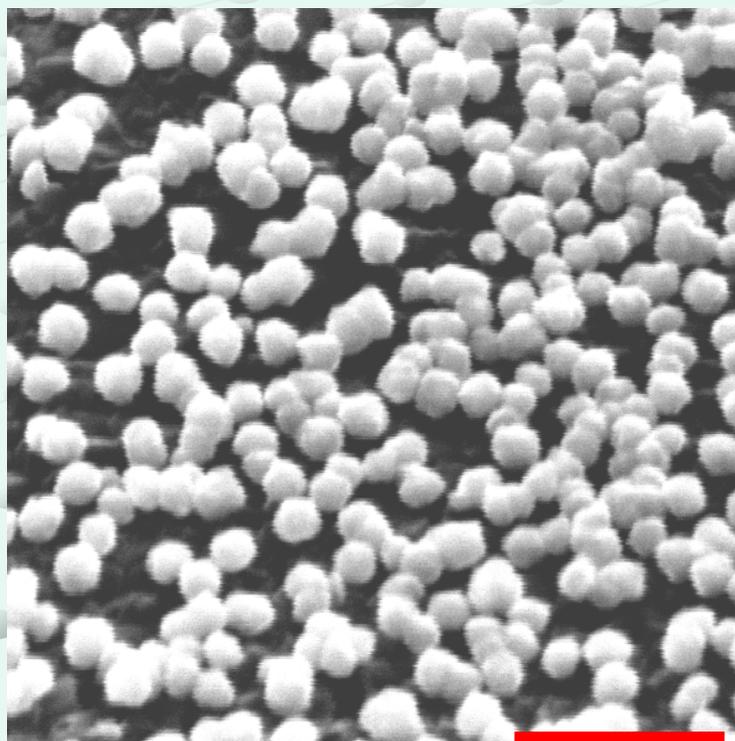
Current for 15 mg/L initial concentration.



- $\text{Cu}^{2+}$  removal rates are independent of the pH value.
- Current efficiency for Cu deposition is greater at pH=4.
  - Same amount of  $\text{Cu}^{2+}$  removal
  - Lower rate of water reduction
  - Smaller electroactive surface area

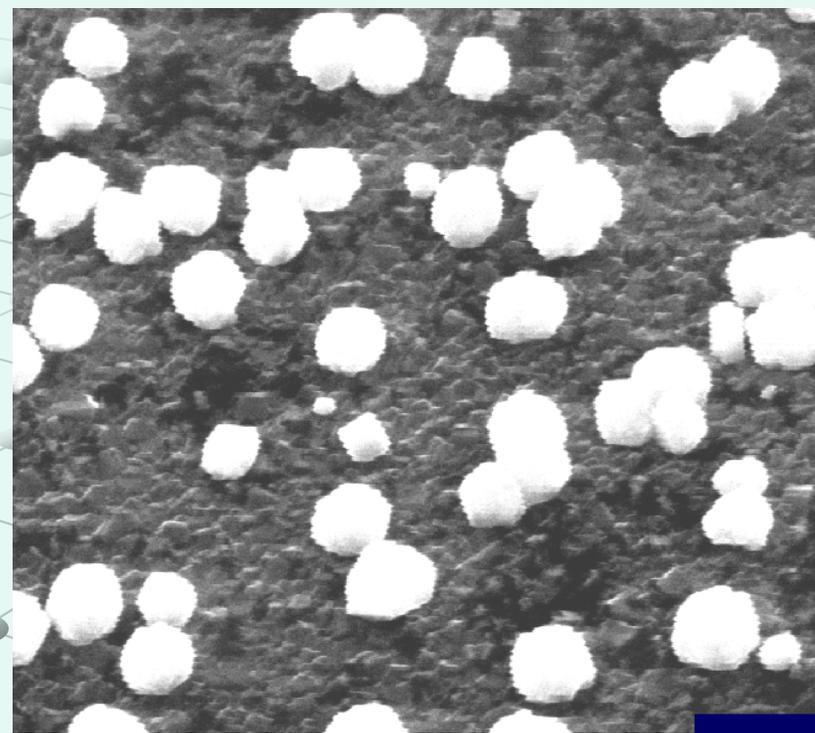
# Effect of pH on Cu Morphology

**pH=6**



**2  $\mu\text{m}$**

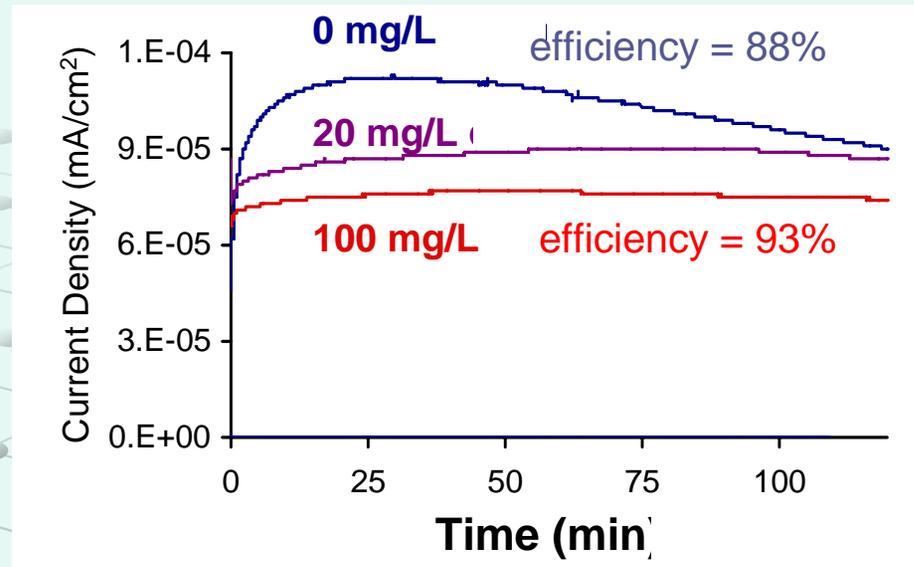
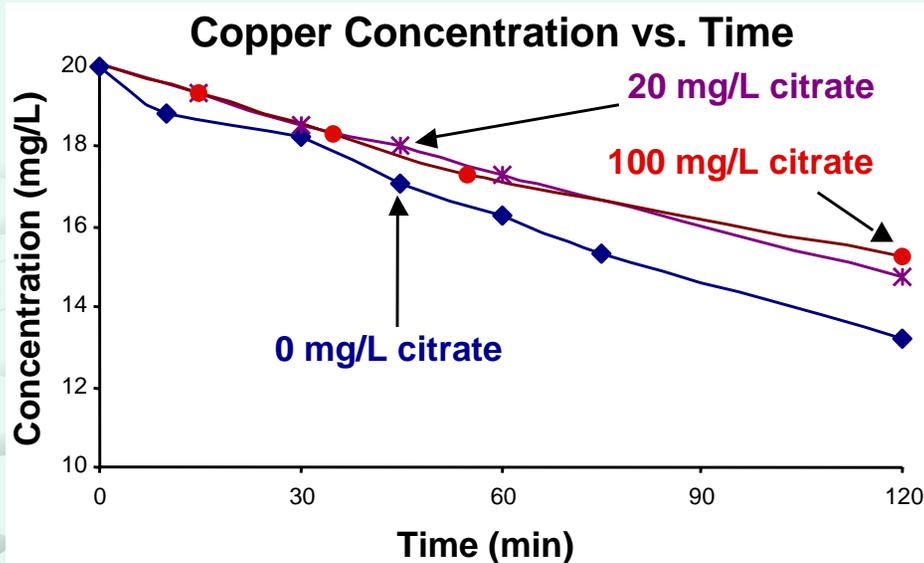
**pH=4**



**2  $\mu\text{m}$**

- Fewer but larger spheres at pH=4: overall smaller electroactive surface area than that at pH=6 leading to higher current efficiency.
- Lower pH may decrease the number of active sites by protonating oxygenated active sites.

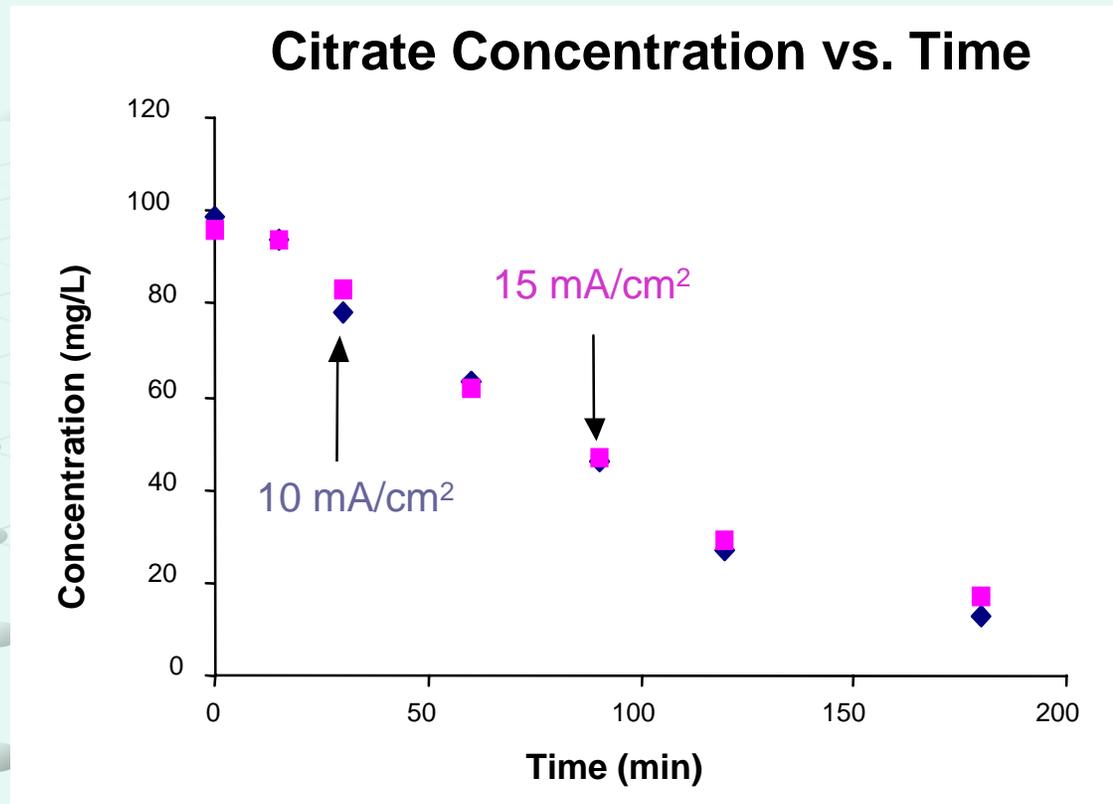
# Effect of Complexing Agents on $\text{Cu}^{2+}$ Removal



- Citrate had a minor effect on the  $\text{Cu}^{2+}$  removal rate.
- Citrate increased the current efficiency for  $\text{Cu}^{2+}$  removal.
- Adsorbed citrate may block sites for  $\text{O}_2$  reduction.

# Citrate Oxidation

$$\frac{dc}{dt} = -k_0$$

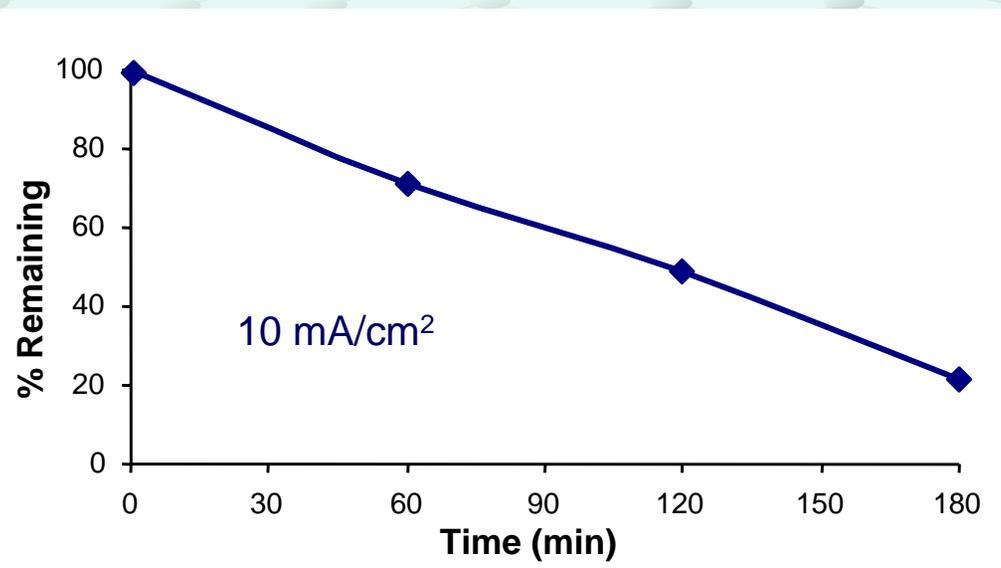


$$\frac{dc}{dt} = -k_1c$$

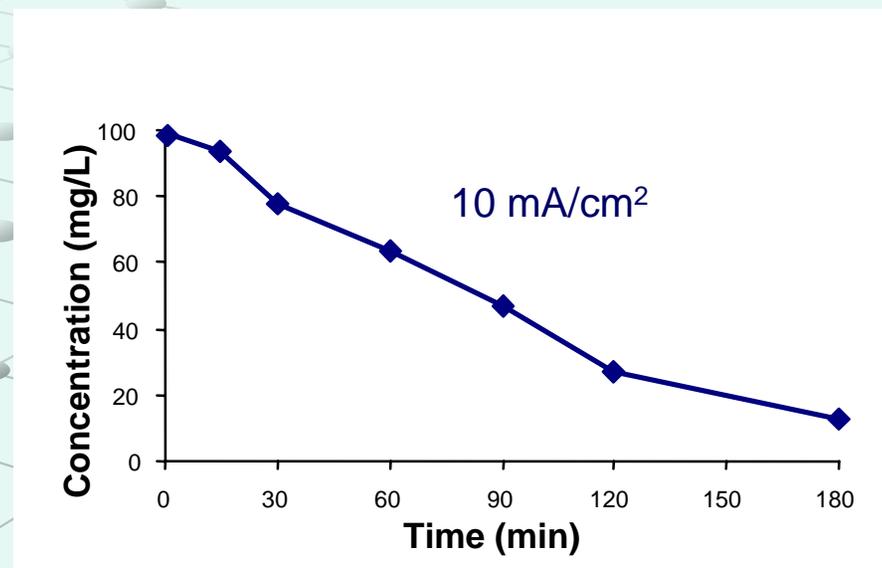
**Citrate removal was independent of the current density, suggesting indirect oxidization by HO<sup>•</sup>**

# Citrate Destruction and TOC Removal

## TOC Remaining vs. Time

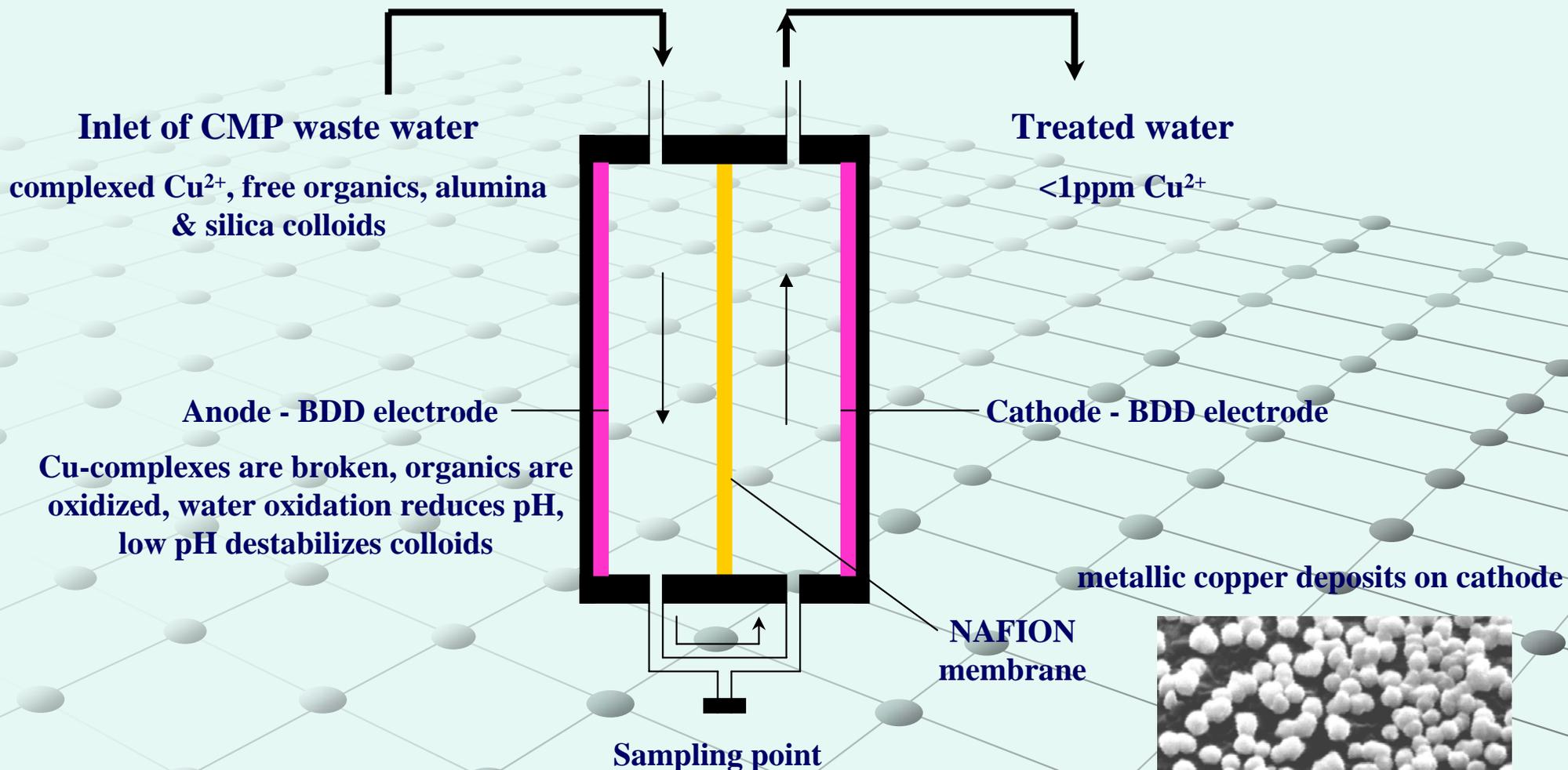


## Citrate Concentration vs. Time

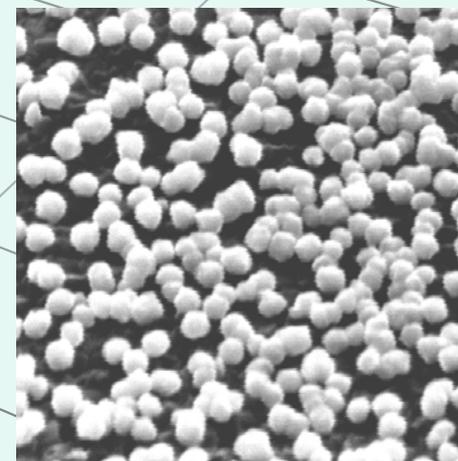


**Similar TOC and citrate removal indicates mineralization to CO<sub>2</sub>.**

# Proposed Treatment Scheme



A single electrochemical reactor could be used in place of the multiple step process that is presently being used for treating CMP wastewater

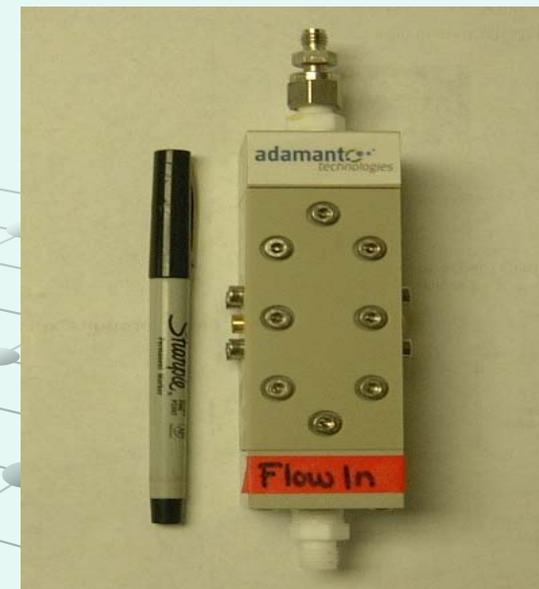
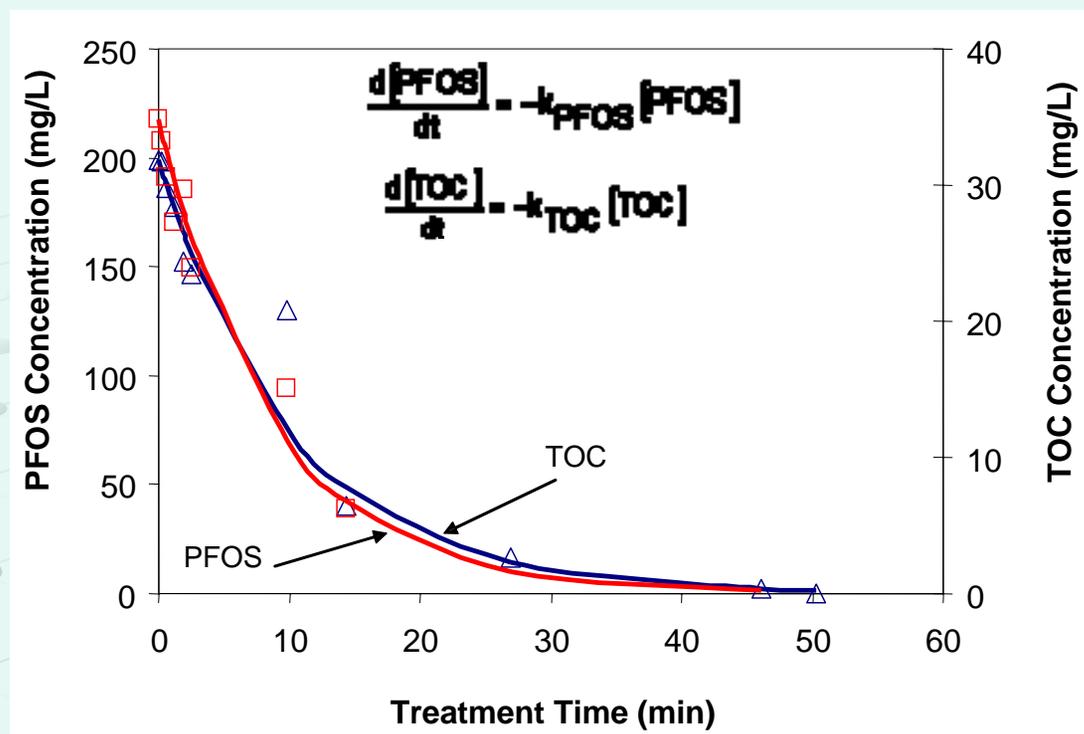


# Example: Destruction of PFOS

- Perfluorooctyl Sulfonate (PFOS) is a perfluorinated surfactant: hydrophilic and hydrophobic
- Extremely low surface tension (2 dynes/cm<sup>2</sup>)
- Widely used in commercial products and industry process
  - Pharmaceuticals, adhesives, Teflon coatings
  - Stain-resistant coatings for fabrics, upholstery, and carpet
  - Paper protectors for food products
  - Semi-conductor industry –
    - Electroplating and electronic etching baths
    - Photographic emulsifiers
    - Surface treatment agents for photolithography
  - Fire extinguishing foams
- Problems with the compound
  - Very stable in environment and accumulate in human body
  - Not degradable by conventional advanced oxidation processes
  - Not biodegradable in wastewater treatment plant
- New technology is needed to remove PFOS from dilute aqueous solutions



# Destruction of PFOS: Experimental Results

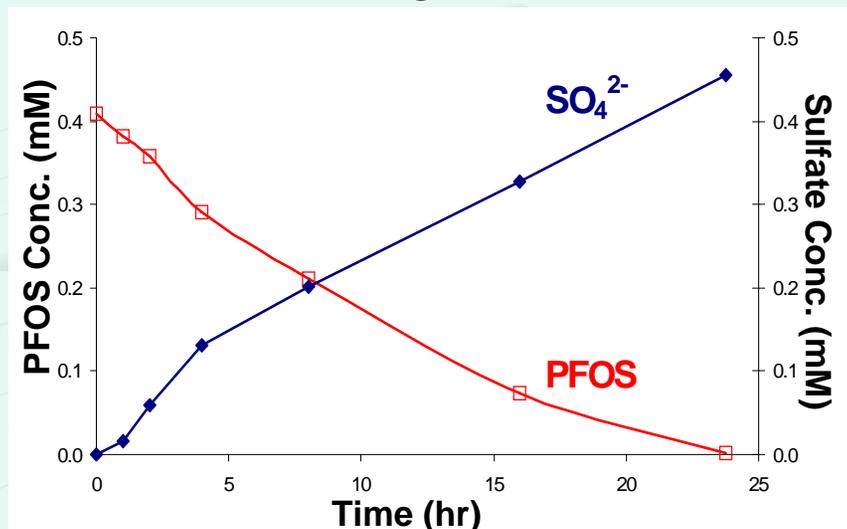


PFOS and total organic carbon concentration (TOC) in flow-cell operated at a current density of 15 mA/cm<sup>2</sup>.

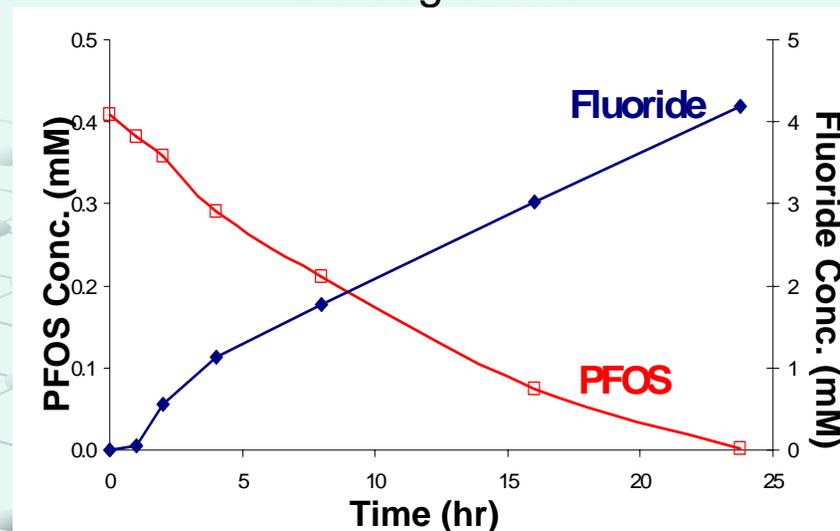
- PFOS can be rapidly removed from water
- Reaction rates are first order
- Treatment half-life less than 10 minutes
- No build-up of fluorinated organic reaction products

# Destruction of PFOS: Reaction Products

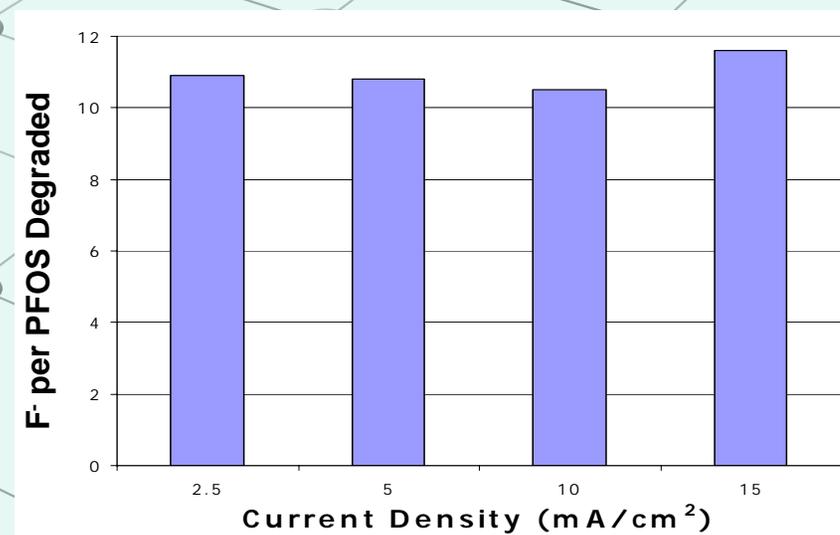
Comparison of sulfate released to PFOS degradation



Comparison of fluoride released to PFOS degradation



Fluoride per PFOS degradation for different current densities.



Only trace quantities of:

- Perfluorooctanoic acid
- Perfluoroheptanoic acid
- Perfluorohexanoic acid

# Proposed Reaction Sequence

PFOS

PFOA



PFOA



Pentafluoropropionic acid



Volatile species

Trifluoroacetic acid

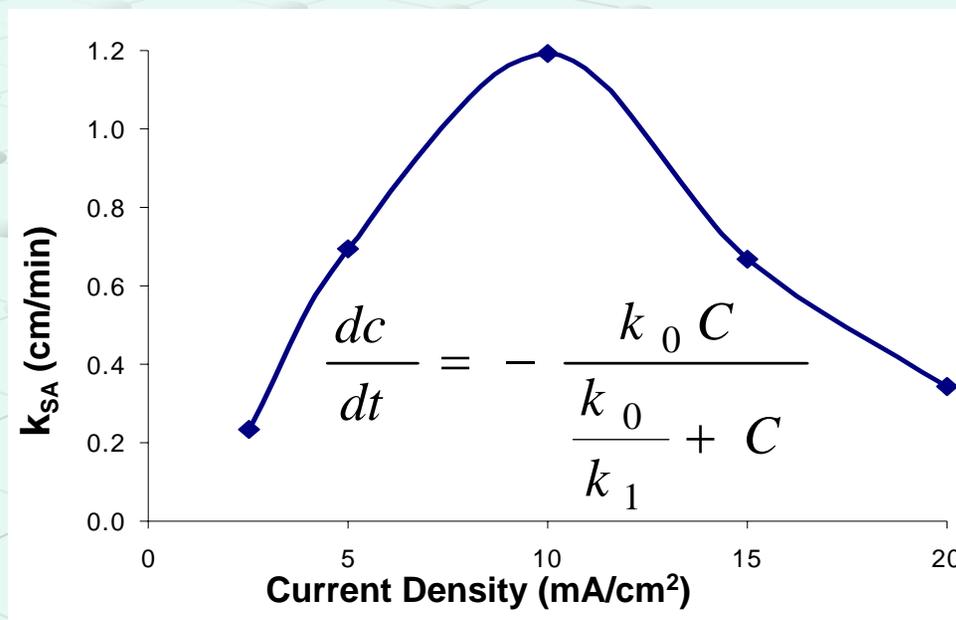


Volatile species

- Fluoride mass balance of 11 F<sup>-</sup> released per PFOS degraded suggests that volatile species are lost from solution.
- Only trace levels of intermediate products suggests near complete FPOS destruction in a single interaction with the electrode surface.

# Effect of Current Density on Reaction Rates

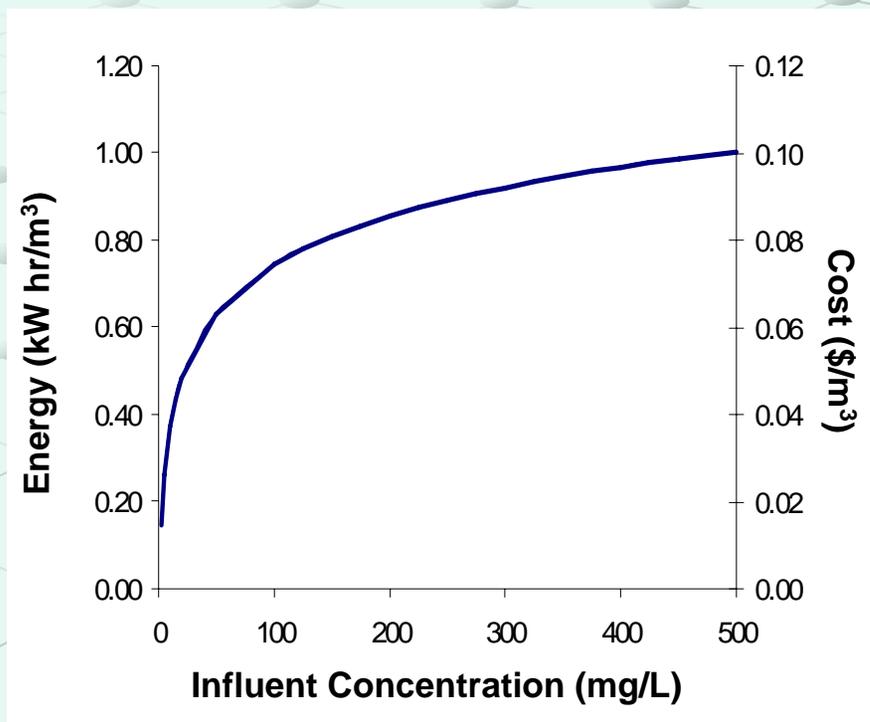
The effect of current density on the RDE surface area normalized rate constants ( $k_{sa}$ ) for PFOS oxidation.



- Oxygen gas bubbles at high current densities reduce the wetted surface area of the electrode and interfere with PFOS oxidation.
- Maximum practical reaction rates are limited by the competing reaction of oxygen evolution.

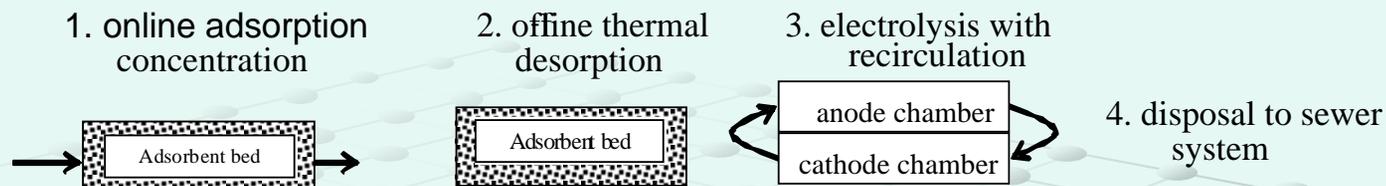
# PFOS Treatment Costs

Electrical power requirements and costs required to reach a final PFOS concentration of 1 mg/L (2.5  $\mu$ M) as a function of the influent concentration. Costs based on flow-cell operated at a current density of 20 mA/cm<sup>2</sup>.



- Electrical power costs are small compared to other treatment methods.
- Capital costs for a 10 liter per minute flow-cell are ~\$5000.

# Proposed Treatment Scheme



## Multi-step treatment scheme:

1. Concentrate target compounds from dilute aqueous solutions on an adsorbent.
2. Thermally desorb PFOS into a concentrated solution.
3. Recirculate concentrated PFOS solution through a BDD electrode reactor for electrolytic destruction.
4. Dispose of biodegradable electrolysis products to the sanitary sewer system.

# Conclusions

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- **Electrochemical treatment at BDD electrode can be used for destructive removal of both inorganic and organic contaminants.**
- **Electrochemical treatment of CMP wastewater at BDD anodes is capable of removing  $\text{Cu}^{2+}$  ions, decomposing organic compounds and decreasing pH in one single reactor.**
- **Organic compounds such as PFOS that cannot be oxidized by chemical and biological treatment process can be treated by electrochemical process.**

# Acknowledgements

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## Industrial Collaboration

- |                     |                         |
|---------------------|-------------------------|
| • Tim Yeakley       | Texas Instruments       |
| • Thomas P. Diamond | IBM                     |
| • Jim Jewett        | Intel                   |
| • Laura Mendicino   | Freescale Semiconductor |